# Strong charge fluctuations manifested in the high-temperature Hall coefficient of high- $T_c$ cuprates

S. Ono, Seiki Komiya, and Yoichi Ando\*

Central Research Institute of Electric Power Industry, Komae, Tokyo 201-8511, Japan (Received 13 October 2006; published 29 January 2007)

By measuring the Hall coefficient  $R_H$  up to 1000 K in La<sub>2</sub>CuO<sub>4</sub>, Pr<sub>1.3</sub>La<sub>0.7</sub>CuO<sub>4</sub>, and La<sub>2-x</sub>Sr<sub>x</sub>CuO<sub>4</sub> (LSCO), we found that the temperature (*T*) dependence of  $R_H$  in LSCO for x=0-0.05 at high temperature undoubtedly signifies a gap over which the charge carriers are thermally activated, which in turn indicates that in lightly doped cuprates strong charge fluctuations are present at high temperature and the carrier number is not a constant. At higher doping (x=0.08-0.21), the high-temperature  $R_H(T)$  behavior is found to be qualitatively the same, albeit with a weakened temperature dependence, and we attempt to understand its behavior in terms of a phenomenological two-carrier model where the thermal activation is considered for one of the two species. Despite the crude nature of the model, our analysis gives a reasonable account of  $R_H$  both at high temperature and at 0 K for a wide range of doping, suggesting that charge fluctuations over a gap remain important at high temperature in LSCO deep into the superconducting doping regime. Moreover, our model gives a perspective to understand the seemingly contradicting high-temperature behavior of  $R_H$  and the in-plane resistivity near optimum doping in a consistent manner. Finally, we discuss possible implications of our results for such issues as the scattering-time separation and the large pseudogap.

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# I. INTRODUCTION

The Hall coefficient  $R_H$  is generally a useful tool to characterize metals and semiconductors, for it reflects the band structure and the sign of charge carriers. In strongly correlated electron materials,  $R_H$  often shows complex dependences on temperature and other control parameters, which are expected to give a clue to understanding the underlying unconventional electronic states; in this context,  $R_H$  has been used for the studies of such novel phenomena as the quantum phase transition<sup>1–4</sup> or charge-stripe formation.<sup>5</sup> Nevertheless, quantitative understandings of  $R_H$  in strongly correlated electron materials have been difficult to achieve, and high- $T_c$ cuprate superconductors are no exception.<sup>6</sup> In fact, since the optimally doped cuprates are just in the middle of the strongand weak-coupling limits,<sup>6,7</sup> even the basic framework for the description of its electronic state is still controversial; as a result, most of the normal-state transport properties, including the Hall coefficient, are generally believed to be too complicated to be quantitatively understood, though there have been attempts to explain their fundamental behavior in the frameworks of specific theories.<sup>8–11</sup>

In this regard, however, the  $R_H$  of high- $T_c$  cuprates appears to be rather peculiar, because in the lightly hole-doped regime where the low-energy physics is apparently governed by the "Fermi arc" (a small portion of the large Fermi surface expected in the absence of electron correlations),<sup>6,12</sup> we have recently found<sup>13</sup> that  $R_H$  simply behaves like the "Hall constant" of a conventional metal and the electron correlations of the Fermi surface in determining  $R_H$ . This finding in cuprates suggests that  $R_H$  might give us a unique opportunity to find a clue to building a proper framework for the description of the electronic state of cuprates despite the strong electron correlations. It should be emphasized that there is still no proper theoretical understanding for *how* the correlation

gap is suppressed (and eventually closed) when carriers are doped to a Mott insulator, so any new information regarding the band structure of doped Mott insulators (to which cuprates belong) would be of fundamental importance for addressing the strong electron correlation problem.

The  $La_{2-x}Sr_{x}CuO_{4}$  (LSCO) system<sup>14</sup> we study here is a prototypical cuprate, where x=0 is a parent charge-transfer (CT) insulator<sup>12,15,16</sup> with the band gap  $\Delta_{CT}$  called the CT gap. We also study another parent CT insulator Pr<sub>1.3</sub>La<sub>0.7</sub>CuO<sub>4</sub> (PLCO) for comparison. In our previous work,<sup>13</sup> besides showing that  $R_H$  of LSCO at low doping can be interpreted as a Hall constant below 300 K, we reported that a marked decrease sets in at higher temperature, which was proposed to be possibly due to the contribution of thermally created holes. In the present work, in an effort to quantitatively understand the temperature dependence and the doping evolution of  $R_H$  in LSCO and to elucidate the electronic structure of this system, we have extended the hightemperature measurements of  $R_H(T)$  to a wide doping range, starting from x=0. As a result, we find that the behavior of  $R_H(T)$  at x=0 is surprisingly simple to understand, despite the strong electron correlations that open the Mott gap in the first place; furthermore, our data in the lightly doped region are found to give a solid basis for understanding the hightemperature behavior in terms of the thermal activation of charge carriers over a well-defined gap. At higher doping, the behavior of  $R_H(T)$  becomes less unambiguous to understand, and in this paper we present our attempt to describe its behavior in terms of a phenomenological two-carrier model.

## **II. EXPERIMENT**

The  $La_{2-x}Sr_xCuO_4$  and  $Pr_{1.3}La_{0.7}CuO_4$  single crystals are grown by the traveling-solvent floating-zone method. The LSCO crystals are annealed to tune the oxygen content to

 $4.000 \pm 0.001$  as described in Refs. 17 and 18. In particular, the oxygen stoichiometry of the x=0 samples (which are annealed in flowing Ar at 800 °C) is confirmed by both the thermogravimetry analysis and the magnetic susceptibility, which shows a very sharp Néel transition at 321 K. The x values shown here are determined by inductively-coupledplasma atomic-emission-spectroscopy analysis. The PLCO crystals are annealed in flowing O2 at 700 °C to minimize oxygen deficiency. To measure  $R_H$  at temperatures up to 1000 K, we use a 6 T superconducting magnet system with a room-temperature bore, in which a water-cooled furnace is fitted. Samples are kept under suitable atmospheres during the experiments to ensure that the oxygen content does not change. For the measurements of  $R_H$  using a standard sixprobe technique, we record the full magnetic-field dependence of the Hall voltage at a fixed temperature by sweeping the magnetic field to both plus and minus polarities, subtract the asymmetric part coming from contact misalignment, and fit the symmetrical part with a straight line to determine  $R_{H}$ , which is essential for the high accuracy achieved in the present work.

Because the present work involves transport measurements in temperatures up to 1000 K which is much higher than usual, it would be prudent to discuss the possibility that the high-temperature Hall data might be adversely affected by the oxygen mobility within a sample or by some change in the oxygen content. As for the oxygen mobility at high temperature, this can in principle provide a parallel channel for charge transport; such an effect is actually important in a mixed ionic and electronic conductors such as  $GdBaMn_2O_{5+x}$  which was recently found to have a very high oxygen mobility,<sup>19</sup> but in LSCO the oxygen-ion conductivity at 1000 K is negligible compared to the electron conductivity. Of more concern might be that the moving oxygen could affect the electron transport in an unexpected way; however, this is very unlikely to be the case in LSCO, because the oxygen diffusion time at 1000 K is of the order of  $10^{-8}$  s, while the electron scattering time is of the order of  $10^{-13}$  s at best, so the electrons see only static oxygen environment during the transport events. Regarding the oxygen content issue, it should be emphasized that in the present experiment the atmosphere in the furnace is optimized for different doping ranges to minimize the change in the oxygen content in the samples during the measurements. For example, in the lightly doped region of LSCO one should only worry about excess oxygen, so the measurements are done in pure argon; on the other hand, in the optimally to overdoped region one should worry about oxygen vacancies rather than excess oxygen, so the measurements are done in 1 atm of oxygen. (Since we cannot avoid noticeable oxygen loss at high temperature for x > 0.20, we show data only up to 700 K for x =0.21 in this work.) Since the oxygen phase diagram is known for the whole range of Sr doping for LSCO,<sup>20</sup> we can be sure that the possible change in the effective hole doping is less than 1% during the measurements up to 1000 K under our measurement conditions. Indeed, the resistivity data monitored upon thermal cycling (warming to 1000 K and cooling to room temperature) are always confirmed to be essentially identical.



FIG. 1. (Color online) Temperature dependences of  $R_H$  up to 1000 K measured on a series of high-quality LSCO single crystals.

## **III. RESULTS**

Figure 1 shows the  $R_H(T)$  data of LSCO single crystals up to 1000 K for the whole doping range studied. Those data are essentially consistent with the previously reported hightemperature data measured on polycrystalline samples,<sup>21,22</sup> but bear much higher accuracies. Note that there have been no high-temperature data for x=0-0.03 even for polycrystalline samples, and it turns out that the data from this insulating regime provide important insights for analyzing the data for higher dopings. In the following, we describe our analyses of the data, starting from the parent insulator, x=0.

#### A. Parent insulators

Interestingly, the temperature dependence of  $R_H$  is found to be most unambiguously understood in the parent CT insulator La<sub>2</sub>CuO<sub>4</sub>, where the electron correlation effects are the strongest; Fig. 2(a) shows the  $R_H(T)$  data up to 1000 K together with the fitting to the formula

$$R_H(T) = \frac{V_{\rm Cu}}{e} (n_0 e^{-\Delta_{imp}/2k_B T} + n_1 e^{-\Delta_{CT}/2k_B T})^{-1}.$$
 (1)

It is clear in Fig. 2(a) that this fitting is essentially perfect, which means that  $R_H(T)$  at x=0 is simply governed by two gaps (*e* is the electron charge and  $V_{Cu}$  is the unit volume per Cu). The lower-temperature part of the data tells us that there is a small concentration ( $n_0=0.57\%$ ) of impurity states located at  $\Delta_{imp}=0.087$  eV above the top of the valence band; such a situation was already known<sup>14</sup> for La<sub>2</sub>CuO<sub>4</sub>, where  $\Delta_{imp}$  determines the impurity-ionization energy.<sup>23</sup> What is new here is that at high temperature above ~500 K another



FIG. 2. (Color online) (a)  $R_H$  of La<sub>2</sub>CuO<sub>4</sub> measured up to 1000 K. The solid line is the fit to the data with Eq. (1) with the parameters  $n_0=0.0057$ ,  $\Delta_{imp}=0.087$  eV,  $n_1=4.3$ , and  $\Delta_{CT}=0.89$  eV. The inset shows a schematic energy diagram for the relevant bands and states. (b) Absolute value of  $R_H$  of Pr<sub>1.3</sub>La<sub>0.7</sub>CuO<sub>4</sub>, which shows a sign change near 700 K.

activation process with  $\Delta_{CT}=0.89$  eV involving a large density of states becomes active, which obviously corresponds to the activation across the CT gap. A schematic energy diagram is shown in the inset of Fig. 2(a). The fact that  $R_H$  is positive at high temperature means that the holes in the valence band are more mobile than the electrons in the conduction band; indeed, if one remembers<sup>16</sup> that the valence band in cuprates is primarily of O 2p character (implying a wide band), while the conduction band is essentially a Cu 3d band (which is always narrow<sup>24</sup>), it is reasonable for the holes to have higher mobility and become dominant. Our fitting yields the prefactor of the high-temperature excitation term,  $n_1$ , as large as 4.3 hole/Cu; although this exceeds the logical limit of 1 hole/Cu, this is actually reasonable because the contribution of the electrons (that are created with holes) tends to reduce the  $R_H$  value and lead to an increase<sup>24</sup> in the effective  $n_1$ <sup>25</sup> In any case,  $n_1$  being larger than 1 hole/Cu strongly suggests that we are observing excitations across major bands.

Figure 2(b) shows similar data for PLCO, which has the so-called T' structure<sup>15</sup> and is the parent insulator for an electron-doped material. The sign of  $R_H$  is negative below 700 K, which indicates that the impurity states (which are presumably due to some oxygen nonstoichiometry) lie close to the conduction band and provides electron carriers at moderate temperature. However,  $R_H$  of PLCO shows a sign change above 700 K, corroborating the conclusion obtained for La<sub>2</sub>CuO<sub>4</sub> that at high temperature the activation across the CT gap becomes relevant and the hole carriers govern  $R_H$  due to their higher mobility.



FIG. 3. (Color online) (a) *T* dependences of  $1/n_{\text{eff}}$  (= $eR_H/V_{\text{Cu}}$ ) for a series of LSCO single crystals in the lightly doped region, *x* = 0.01–0.05, with their fits (solid lines) using Eq. (2). The fitting parameters  $n_1$  and  $\Delta_{CT}$  are shown in (b) and (c).

We note that our  $\Delta_{CT}$  obtained for La<sub>2</sub>CuO<sub>4</sub> gives the thermodynamically measured CT gap, and this is to be compared with the optically measured CT gap,<sup>12,14</sup> which is usually believed to be about 2 eV. Here, a little caution is needed, because it is customary to take the *peak energy* of the optical absorption as a measure of the CT gap, but this energy does not correspond to the true gap that is best measured as the minimum excitation energy between the two bands and is equal to the distance between the two band edges. When we take the onset of the optical absorption as a measure of the CT gap, the existing optical data<sup>14</sup> give values of 0.9–1.3 eV, which is still a bit larger than our thermodynamic value of 0.89 eV. An obvious reason for this difference is that the CT gap is an indirect one,<sup>26</sup> but additionally our  $\Delta_{CT}$  is measured at high temperature, where the weakening of the antiferromagnetic correlations and the band broadening would also reduce  $\Delta_{CT}$ . Furthermore, polaron effects are likely to be important in insulating cuprates,<sup>14,27</sup> and these effects would naturally reduce the gap at high temperature.<sup>14</sup> Hence, one may conclude that the CT gap manifested in the Hall effect at x=0 is fully consistent with the optics data.

## B. Lightly doped region

Now that  $R_H(T)$  of La<sub>2</sub>CuO<sub>4</sub> is quantitatively understood, let us see how we can extend this understanding to the lightly doped region. Figure 3(a) shows the  $R_H(T)$  data of LSCO for x=0.01-0.05 in a semilogarithmic plot, where  $R_H$  (cm<sup>3</sup>/C) is converted into the inverse of the effective carrier number per Cu,  $1/n_{\text{eff}}$  (= $eR_H/V_{\text{Cu}}$ , which is nondimensional), for the ease of understanding the meaning of the numbers. Since the plateau in  $R_H(T)$  at moderate temperature gives  $n_{\text{eff}}$  that is essentially equal to x at low doping,<sup>13</sup> the impurity term  $n_0e^{-\Delta_{imp}/2k_BT}$  in Eq. (1) should be replaced with x to describe  $R_H(T)$  in this region.<sup>28</sup> Hence, we fit the data for x =0.01-0.05 to

$$R_H(T) = \frac{V_{\rm Cu}}{e} (x + n_1 e^{-\Delta_{CT}/2k_B T})^{-1}.$$
 (2)

The solid lines in Fig. 3(a) are the results of the fittings.<sup>29</sup> Note that the upturn at very low temperature seen in all the data is due to the strong Anderson localization<sup>13</sup> that reduces the number of mobile carriers and naturally causes a deviation from Eq. (2). Obviously, Eq. (2) gives a reasonable account of the essential features of the data (except for the Anderson localization), and hence one may conclude that the thermal activation of holes gives rise to the exponential decrease in  $R_H$  at high temperature not only at x=0 but also at low doping. This in turn indicates that there are strong charge fluctuations in lightly doped cuprates at  $\geq 400$  K, where the charge transport must become incoherent; therefore, it is probably not reasonable to describe  $R_H$  in this regime using theories developed for a metallic system (i.e., for coherent electrons with well-defined wave vectors), such as that in Ref. 10.

The doping dependences of the parameters  $n_1$  and  $\Delta_{CT}$  in Eq. (2) obtained from the fits are shown in Figs. 3(b) and 3(c). It is notable that  $n_1$ , a rough measure of the number of available states for thermal activations (but is amplified by various additional effects<sup>24,25</sup>) is essentially doping independent for x=0-0.05 [Fig. 3(b)], which would imply that thermal creations of carriers of essentially the same nature are taking place in this doping range. On the other hand, the gap  $\Delta_{CT}$  for the thermal activation [Fig. 3(c)] shows a sudden drop from 0.89 to 0.53 eV upon doping only 1% of holes to the parent insulator, but then shows only a small decrease with x. Probably, there are two possibilities to interpret this result. One is to take the reduction in  $\Delta_{CT}$  to be a result of the softening of the main CT gap upon slight doping; in this case, the same bands are involved in the activation process after the doping, and our observation that  $n_1$  is essentially doping independent is in good accord. Considering the fact that doping to a Mott insulator necessarily involves a change in the electronic structure at a high energy scale of the order of the on-site repulsion U (because doping one hole to a Mott insulator not only creates a hole state but also removes one state from the upper Hubbard band),<sup>30</sup> it would be possible that a slight doping induces a relatively large change in the band structure. The other possibility is that the so-called ingap states<sup>12</sup> are created in the middle of the original CT gap upon hole doping and our  $\Delta_{CT}$  actually measures the chargetransfer excitations from these new states to the upper Hubbard band (conduction band). In this case, one would expect  $n_1$  for  $x \ge 0.01$  to be much smaller than that for x=0; however, a large  $n_1$  might be possible for some particular shape of the band edge,<sup>31</sup> so our result in Fig. 3(b) cannot conclusively exclude this possibility. In any case, the true nature of  $\Delta_{CT}$  in the doped system is best left as an open question, and its identification is actually at the heart of understanding what really happens upon doping to a Mott insulator. It is intriguing to note that our  $\Delta_{CT}$  for the lightly doped region coincides rather well with the peak frequency of the mid-infrared (MIR) absorption seen in the optical conductivity of LSCO,<sup>32</sup> so the MIR absorption may also have something to do with the CT excitations.

In passing, previous studies of the doping dependence of the CT gap using high-energy probes<sup>33,34</sup> have found a hardening of the gap, which appears to be at odds with the first possibility discussed above. However, Markiewicz and Bansil argued<sup>26</sup> that those high-energy experiments may only see hard branches of the various modes of the CT excitations; naturally, our thermodynamic measurement probes the CT excitation of the lowest energy, which may not be easily seen by the high-energy probes. In this regard, it should be noted that our  $\Delta_{CT}$  measures the effective excitation energy *at high temperature*, which is naturally smaller than the band gap at T=0, so care must be taken when comparing our  $\Delta_{CT}$  to that calculated theoretically for T=0.

#### C. Superconducting doping range

At higher doping  $x \ge 0.08$ , Eq. (2) becomes obviously inappropriate, because  $n_{\rm eff}$  at moderate temperature is no longer equal to x.<sup>13</sup> Also, the plateau in  $R_H(T)$  at moderate temperature observed in the lightly doped region is now replaced by a peaked temperature dependence, which points to the necessity of an elaborate model to understand its behavior at low to moderate temperature. Nevertheless, as is obvious in Fig. 1, in those samples the behavior of  $R_H(T)$  at high temperature is surprisingly similar to that observed in lightly doped samples and is changing only gradually with doping; this observation strongly suggests that essentially the same thermal activation process is affecting the  $R_H(T)$  behavior at high temperature even in the superconducting doping range.<sup>35</sup> Motivated by this qualitative observation, we attempt to understand the high-temperature  $R_H(T)$  behavior for  $x \ge 0.08$  in terms of a crude phenomenological two-carrier model, remembering that the occurrence of an electronic heterogeneity (microscopic phase separation or coexistence of different types of carriers) has been discussed repeatedly for LSCO;<sup>6,36–41</sup> for example, doping evolutions of the magnetic susceptibility<sup>36</sup> or the superfluid density<sup>37</sup> have been discussed to reflect an electronic heterogeneity. In the following analysis, we crudely hypothesize that there are two types of holes, those that exist on the Fermi arc (or small hole pockets), and others that exist on a large Fermi surface (FS). We suppose that the former contribute to the Hall effect with the component  $R_H^{arc}$  described by Eq. (2), while the latter contribute with a component  $R_H^{LFS} = V_{Cu}/en_2$ . For the sake of simplicity, we further suppose that these two components  $R_H^{arc}$ and  $R_{H}^{LFS}$  are additive in the expression of the total Hall coefficient with their respective fractions f and 1-f, as is the case with the two-carrier model proposed for cuprates by Lee and Nagaosa.<sup>42</sup> Hence, we try to see how  $R_H(T)$  at high temperature can be described in terms of the expression



FIG. 4. (Color online) The  $R_H(T)$  data, converted into the nondimensional  $1/n_{\text{eff}}$ , for x=0.08-0.21 and their fits (solid lines) using Eq. (4). The squares at T=0 mark  $R_H(0)$  obtained from pulsed magnetic-field experiments (Ref. 45): The  $R_H(0)$  value for x=0.08is obtained by extrapolating the data in Ref. 45 for 10-40 K to  $T \rightarrow 0$ ; for x=0.15, 0.18, and 0.21, the  $R_H(0)$  values are obtained by a simple interpolation of those for x=0.14, 0.16, 0.17, 0.20, and 0.22 reported in Ref. 45. The dashed lines are guides to the eyes.

$$R_{H}(T) = f R_{H}^{arc} + (1 - f) R_{H}^{LFS}$$
(3)

$$= \frac{V_{\text{Cu}}}{e} [f/(x + n_1 e^{-\Delta_{CT}/2k_BT}) + (1 - f)/n_2].$$
(4)

We emphasize that Eq. (4) should be considered to be essentially a working hypothesis that is not backed by a concrete theory, and this expression naturally fails at low to moderate temperature where  $R_H$  shows a nontrivial temperature dependence due, for example, to the scattering-time anisotropy.<sup>9,43</sup> Actually, already in the upper end of the lightly doped region discussed in the previous subsection (i.e., x=0.04 and 0.05), a slight deviation of the data from the fitting is evident below 300 K in Fig. 3(a), which is likely to be due to the intrinsic temperature dependence of  $R_H$  in the coherent regime.

The solid lines in Figs. 4(a)-4(e) show the fits of the data



FIG. 5. (Color online) Doping dependences of the fitting parameters for  $R_H(T)$  of LSCO. (a)  $n_1$ , a rough measure of the number of available states in the bands relevant to the thermal activation in the component  $R_H^{arc}$  which is presumably associated with the Fermi arc; (b) f, fraction of the component  $R_H^{arc}$ ; (c)  $n_2$ , effective hole number in the component  $R_H^{LFS}$  presumably associated with a large Fermi surface; (d)  $\Delta_{CT}$ , energy gap for the thermal activation.

for x=0.08-0.21 to Eq. (4). It is rather surprising that our crude model very well describes the experimental data for T > 300 K. As is noted above, it is expected from the beginning that Eq. (4) does not fit the data at low to moderate temperature, but intriguingly the value of  $R_H$  in the plateau region of our fit turned out to bear reasonable physical meaning: Remember, it is known from the pulsed high-magneticfield experiments<sup>1,44,45</sup> that the normal-state Hall coefficient in the  $T \rightarrow 0$  limit,  $R_H(0)$ , which is expected to genuinely reflect the electronic structure,<sup>43</sup> is much smaller than that at  $T_c$ . We plot  $R_H(0)$  obtained from recent measurements<sup>45</sup> of LSCO with squares in Figs. 4(a)-4(e), and they agree reasonably well with what our fittings would suggest.<sup>46</sup> This gives phenomenological support to the validity of Eq. (4), and implies that the evolution of the effective carrier density at low temperature, which would be directly reflected in the measured  $R_H$  for  $T \rightarrow 0$ , may be understood in the framework of a two-carrier model in LSCO. The apparent success of our crude model in describing the  $R_H$  values at both high temperature and 0 K at the same time seems to suggest that there is a certain truth in the above approach and calls for theoretical attention.

The doping dependences of the fitting parameters are shown in Fig. 5, in which the results for the parent insulator and the lightly doped samples discussed in the previous subsections are combined. It is notable that  $n_1$  is essentially doping independent up to x=0.18 [Fig. 5(a)], which suggests that the physical origin of the thermally activated contribution is essentially unchanged up to optimum doping. On the other hand, the fraction f for the component  $R_H^{arc}$ , in which the thermal activation is relevant, decreases rapidly for x > 0.05 [Fig. 5(b)], which causes the overall temperature dependence in  $R_H$  to become weaker as the overdoped region is approached. The parameter  $n_2$ , the effective hole number associated with the large FS, is of the order of 1 as expected [Fig. 5(c)], and its doping dependence is likely to reflect the



FIG. 6. (Color online) Arrhenius plot of the activation term  $n_{act}$ , obtained from the  $R_H$  data by subtracting the constant contributions, for all *x* values. The solid lines are straight-line fits to the data to emphasize the activated behavior.

change in the FS shape observed by angle-resolved photoemission spectroscopy experiments;<sup>12</sup> namely, as the shape of the large FS changes from holelike to electronlike upon overdoping,  $R_H^{LFS}$  is expected to present a sign change, and hence  $n_2 (=V_{Cu}/eR_H^{LFS})$  should eventually diverge.

To demonstrate the quality of our analysis, we show in Fig. 6 the Arrhenius plot of the activation term  $n_{act}$  $[=(n_1/f)e^{-\Delta_{CT}/2k_BT}]$ , which is obtained from the  $R_H$  data after subtracting the constant contribution from the  $R_H^{LFS}$ component and that in the  $R_H^{arc}$  component; namely, after determining all the parameters of Eq. (4),<sup>46</sup> we obtain  $n_{act}$  by calculating  $[eR_H/V_{Cu}-(1-f)/n_2]^{-1}-(x/f)$ . Remember, the constant contributions used for calculating  $n_{act}$  from the raw  $R_H$  data are justified by the reasonable agreement between  $R_H(0)$  and our fits for  $T \rightarrow 0$ . Figure 6 clearly testifies that the T dependence of  $R_H$  above ~300 K is of activated nature.

As discussed in Sec. III B, the gap  $\Delta_{CT}$  for the thermal activation [Fig. 5(d)] shows a sudden drop from x=0 to 0.01 and then shows only a small decrease with x in the lightly doped region where our analysis for obtaining  $\Delta_{CT}$  is robust. This weak doping dependence of  $\Delta_{CT}$  appears to continue into the superconducting doping range, although one should take this result with a grain of salt, given the crude nature of our analysis for this region. Nevertheless, it is probably reasonable to conclude from our analysis that there remain charge fluctuations associated with some charge-transfer excitations deep into the superconducting doping region, and such fluctuations keep causing a thermally activated temperature dependence in  $R_H$  at high temperature.

# **IV. DISCUSSION**

The doping dependence of f shown in Fig. 5(b) suggests that the crossover in dominance from the Fermi arc to the large FS is pivoted at x=0.08, and intriguingly this crossover around x=0.08 appears to be reflected in a qualitative change in the temperature dependence of the in-plane resistivity  $\rho_{ab}$ .



FIG. 7. (Color online) *T* dependences of the product  $x\rho_{ab}$  for x=0.01-0.18 up to 1000 K; note that *x* is a nondimensional parameter.

This situation is most easily seen in the plot of  $x\rho_{ab}$  vs T up to 1000 K shown in Fig. 7; here, the data for x=0.01-0.05show a clear tendency toward saturation at high temperature, which presumably comes from the increasing number of thermally created holes, whereas such a tendency is mostly absent in the data for x=0.12-0.18 where the thermal activation occurs only in the minority component. It is useful to note that, within our model, the contribution from  $R_{H}^{arc}$  to the total  $R_H$  remain relatively large at low temperature even when f is small because of the smallness of x compared to  $n_2$ [note that  $R_H$  at low temperature is written as  $(V_{Cu}/e){f/x}$  $+(1-f)/n_2$ ]; for example, even though f is only 0.2 at x =0.18, roughly 2/3 of the total  $R_H$  is due to the component  $R_{H}^{arc}$  at low temperature, which is responsible for the 60% decrease in the total  $R_H$  from 200 to 950 K. Hence, it is possible that  $\rho_{ab}$  is insensitive to what is happening in the minority component, while  $R_H$  is more sensitive to the thermal activations taking place in the minority component.

It is useful to mention that in cuprates there is a celebrated "scattering-time separation" of charge carriers (i.e., the T dependences of resistivity and cotangent of the Hall angle,  $\cot \theta_H$ , present different powers of T).<sup>6</sup> In our data,  $\cot \theta_H$ behaves as  $\sim T^2$  only below  $\sim 400$  K in the superconducting doping range (Fig. 8), which suggests that the deviation of  $R_H$  from the fittings shown in Figs. 4(a)-4(e) may be linked to the appearance of two scattering times. This is reasonable, because thermally created carriers are incoherent and blur the scattering-time separation at high temperature; also, the scattering-time separation would disappear at low enough temperature where the elastic impurity scattering dominates, if it is due to a development of scattering-time anisotropy in the momentum space.<sup>9,43,47,48</sup> Hence, our data seem to suggest that the scattering-time separation is a result of a peculiar scattering-time anisotropy,<sup>9,47,48</sup> which develops only at intermediate temperature. In passing, similar scattering-time separations have been found in noncuprate materials,<sup>2,4,49,50</sup> suggesting that this phenomenon may not be very special.

It is worth emphasizing that the picture derived here (appearance of activated carriers at high temperature and growth



FIG. 8. (Color online) Plots of  $\cot \theta_H$  (at 1 T) vs  $T^2$  for three representative dopings. The solid lines emphasize the  $T^2$  law that holds at low temperature.

of the contribution from a large FS in the superconducting doping range) not only explains the Hall effect but also is consistent with the resistivity data, as can be inferred in Fig. 7. Also, the magnetic susceptibility data up to 800 K (Ref. 51) have been analyzed<sup>36</sup> with a similar model and are essentially consistent with our conclusion. In view of the present picture, we can probably address some of the complications regarding the pseudogap.<sup>6</sup> In the past, a scaling of  $R_H(T)$  was used<sup>22</sup> to identify a characteristic temperature  $T^*$ that reaches ~700 K at low doping, and this  $T^*$  was shown to agree with those deduced from the dc magnetic susceptibility or the Knight shift. Since this  $T^*$  is much higher than the pseudogap temperature deduced from spectroscopic means,<sup>6</sup> it is often called a "large pseudogap." Our results imply that the large pseudogap is related to the freezing of the thermal creation of charge carriers, which causes the chemical potential to move and thereby affects various physical quantities.

#### **V. CONCLUSION**

We have shown that the behavior of  $R_H(T)$  in insulating LSCO (x=0-0.05) at high temperature clearly signifies that charge carriers are thermally activated over a sub-eV gap, likely associated with some charge-transfer excitations. In the superconducting doping region, the high-temperature  $R_H(T)$  behavior is found to be qualitatively the same but is weakened, which we try to describe with a phenomenological two-carrier model that considers the thermal activation for one of the two components. Besides giving a perspective to consistently understand the high-temperature behavior of  $R_H$  and  $\rho_{ab}$ , our model allows us to understand the  $R_H$  value both at high temperature and at 0 K for a wide range of doping, despite its crudeness. Overall, our data and analysis strongly suggest that charge fluctuations associated with a sub-eV gap should be taken into account when discussing the physics of cuprates even at relatively low energy scales. Implications of this conclusion include the following. (1) Breakdown of the  $T^2$  law of cot  $\theta_H$  at high temperature may be related to the onset of incoherence in one of the two species of carriers, which dominates the Hall effect but little influences the resistivity near optimum doping; (2) "opening of a large pseudogap" may actually be a "freezing of charge fluctuations" associated with the Fermi arc.

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- \*Corresponding author. Email address: ando@criepi.denken.or.jp
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